

Notice of References Cited	Application/Control No. 09/809,440	Applicant(s)/Patent Under Reexamination HOUGHAM, GARETH	
	Examiner Monica A Fontaine	Art Unit 1732	Page 1 of 1

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	B	US-5,512,131	04-1996	Kumar et al.	216/13
	C	US-5,731,253	03-1998	Sangokoya, Samuel A.	502/102
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	M	US-			

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NON-PATENT DOCUMENTS

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	U	"Siloxane Polymers for High-Resolution, High-Accuracy Soft Lithography." B. Michel et al. Macromolecules 33 (8), 3042-3049, 2000.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.